

Notice of References Cited	Application/Control No. 10/798,974		Applicant(s)/Patent Under Reexamination HATANO ET AL.	
	Examiner Martin J. Angebranndt		Art Unit 1756	Page 1 of 2

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-4,144,117	03-1979	Fukuda et al.	117/27
*	B	US-2003/0064294	04-2003	Kitamura et al.	430/1
*	C	US-6,856,433	02-2005	Hatano et al.	359/7
*	D	US-6,373,806	04-2002	Kitamura et al.	369/103
*	E	US-6,535,472	03-2003	Lee et al.	369/103
*	F	US-5,440,669	08-1995	Rakuljic et al.	359/7
*	G	US-2002/0176126	11-2002	Psaltis et al.	359/15
*	H	US-6,670,079	12-2003	Kitamura et al.	430/1
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

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	N	2001-004801	01-2001	Japan	Kitamura et al.	***
	O	2001-066976	03-2001	Japan	Furukawa et al.	**
	P	2001-066977	03-2001	Japan	Ri et al.	***
	Q					
	R					
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	Furukawa et al. "Stoichiometric LiTaO3 for dynamic holography in the near UV wavelength range", Jap. J. Appl. Phys., Vol 38 pt. 13B 1816-1819 (1999).			
	V	STN Abstract of Kitamura "Breakthrough in ferroelectric single crystals for optical applications control of non-stoichiometric defects", Oyo Butsuri, Vol 69(5) pp. 511-517 (2000), dated 5/2000.			
	W	Wevering et al., "Relaxation of light induced absorption changes in photorefractive lithium tantalate crystals", JOSA B Vol. 18(4) pp. 472-478 (2001)			
	X	Imbrock et al., "Nonvolatile holographic storage in photorefractive lithium tantalate crystals with laser pulses", JOSA B vol. 16(9) pp. 1392-1397 (1999)			

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

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	N					
	O					
	P					
	Q					
	R					
	S					
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	STN abstract of Glass et al., "Optical index damage in electrooptic crystals", NBS Spec. pub. No. 372 pp. 15-26 (1972) ✓
	V	Machine translation of JP 11-035393 ✓
	W	
	X	

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